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1756  
3/24/03  
#81 response

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of : Hiroko IWASAKI

Serial No. : 09/836,144

Group Art Unit: 1756

Date Filed : April 17, 2001

Examiner: J. McPherson

For : OPTICAL DATA RECORDING MEDIUM AND MATERIAL FOR  
HEAT-RESISTANT PROTECTION LAYER FOR THE SAME

1185 Avenue of the Americas  
New York, N.Y. 10036

Commissioner for Patents  
Washington, D.C. 20231

RESPONSE TO CLAIM RESTRICTION REQUIREMENT

This is a response to the Office Action dated June 10, 2003 requiring restriction of inventions under 35 U.S.C. 121. The office action indicates that applicant should elect one of the nitrides from claims 11-13. In response applicant elect with traverse the nitride disclosed in claim 12. Silicon nitride

The restriction requirement is traversed because it is believed that all of the claimed inventions are sufficiently related to each other to be examined in one patent application:

Respectfully submitted,

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I hereby certify that this paper is being deposited this date with the U.S. Postal Service as first class mail addressed to: Commissioner of Patents and Trademarks, Washington, D.C. 20231.	
	July 10, 2003
Richard F. Jaworski	Date
Reg. No. 33,515	